High-Index Topological Insulator Resonant Nanostructures from Bismuth Selenide

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Abstract

Topological insulators (TIs) are a class of materials characterized by an insulting bulk and high mobility topologically protected surface states, making them promising candidates for future optoelectronic and quantum devices. Although their electronic and transport properties have been extensively studied, their optical properties and prospective photonic capabilities have not been fully uncovered. Here, we use a combination of far-field and near-field nanoscale imaging and spectroscopy, to study CVD grown Bi₂Se₃ nanobeams (NBs). We first extract the mid-infrared (MIR) optical constants of Bi₂Se₃, revealing refractive index values as high as $n \sim 6.4$, and demonstrate that the NBs support Mie-resonances across the MIR. Local near-field reflection phase mapping reveals domains of various phase shifts, providing information on the local optical properties of the NBs. We experimentally measure up to 2π phase-shift across the resonance, in excellent agreement with FDTD simulations. This work highlights the potential of TI Bi₂Se₃ for quantum circuitry, non-linear generation, high-Q metaphotonics, and IR photodetection.

Keywords: Topological insulator, bismuth selenide, Mie-resonator, mid-infrared, scanning near-field optical microscopy.

Topological insulators (TIs) constitute a distinct class of materials characterized by an energy gap in the bulk (insulator like), while also hosting time-reversal symmetry protected gapless surface states.^{1–4} Fundamentally, TIs have strong spin-orbit coupling with the edge states allowing flow of unidirectional supercurrent. These novel quantum states have been theoretically predicted as well as experimentally demonstrated in a wide variety of materials and systems⁵ such as CdTe/HgTe/CdTe quantum wells,⁶ strained HgTe,⁷ Sb₂Te₃/Sb₂Te_{3-y}Se_y,^{8–11} Bismuth selenide (Bi₂Se₃),^{9,12–15} Bi₂Te₃,^{9,16} Bi_{2-x}Sb_xTe_{3-y}Se_y,¹⁷ MnBi₂Se₄,¹⁸ ZrTe₅¹⁹ and more, with extensive research towards realizing novel electronic devices.^{20,21} Recently, the unique properties of TIs have been explored in the context of electromagnetic and photonic systems.^{22–30} Chalcogenide TIs are particularly interesting as they possess narrow bulk bandgap,^{16,31} exhibit extremely high permittivity values,^{32,33} and strong anisotropic behavior.³⁴ Recent demonstrations such as high harmonic generation,^{29,35} plasmonic properties in the ultraviolet to visible range^{36,37} and high mobility surface states in the mid-infrared (MIR) and THz spectral ranges,^{13,38,39} exemplify the potential of TIs,^{13,29,33,36,38–42}

Among these systems, Bi₂Se₃, a strong 3D TI with a large room temperature (RT) bulk energy gap of ~0.3-0.35 eV, and high permittivity values, is an interesting TI material for photonic applications.^{9,15,43-48} Previous theoretical and experimental investigations have indicated that Bi₂Se₃ is a high-index material with the real part of the refractive index (RI) peaking around n~5.3-5.8 for the NIR regime, depending on the number of layers^{46,49}, while other studies have primarily focused on understanding the light-matter interaction in Bi₂Se₃ within the NIR to MIR spectral ranges.⁵⁰⁻⁵² However, experimentally measured fundamental properties such as permittivity, RI, and optical anisotropy in these TIs are still lacking in the infrared range, as well as the photonic capabilities of both bulk and nanostructured Bi₂Se₃. In this work we study the MIR optical properties of TI Bi₂Se₃ and utilize them to demonstrate high-index Mie-resonant nanostructures in chemical vapor deposition (CVD) grown Bi₂Se₃ nanobeams (NBs). Using infrared spectroscopy, along with multiple Lorentz-Drude oscillator modeling that accounts for both the bulk and the surface metallic states, we extract the optical constants of Bi₂Se₃ and demonstrate that this material system has RI values as high as $n \sim 6.4$, with minimal losses across the MIR range. Polarized Fourier-transform infrared (FTIR) spectroscopy reveals that the NBs exhibit TE and TM Mieresonant modes with the fundamental mode confined within nanobeams having cross-section sizes smaller than $\lambda/8$. We use scattering-type scanning near-field optical microscope (s-SNOM) to perform nanospectroscopy and extract the amplitude and phase of z-polarized resonant modes. Local near-field phase mapping reveals in-plane inhomogeneity allowing to estimate local variations in the complex optical constants and losses in the NBs. We experimentally demonstrate up to 2π phase shift across the resonance, for NBs placed on gold (Au) substrates. We highlight the role of loss in the phase pickup in the NB resonators and show that small changes in the imaginary part of the RI (k) lead to large variations in the phase. The results highlight the potential of Bi₂Se₃ as a versatile material for nanophotonic applications, by combining ultracompact components with very high-index values and low losses, that are coupled with topological quantum properties.

Bi₂Se₃ NBs were grown on sapphire substrate with typical substrate sizes of ~1 cm², using CVD. Details of the synthesis procedure can be found in the supporting information (SI). Structural characterization of the as-synthesized nanostructures shows that they were in the form of NBs of varying dimensions (SEM, Figure 1a), while elemental mapping using energy dispersive X-ray (EDAX) spectroscopy (Figure 1b), revealed that the NBs are indeed composed of pure Bismuth (Bi) and Selenium (Se) elements.



Figure 1. Material characterization of the CVD grown NBs. (a) SEM image of an ensemble of NBs and (b) that of a single NB together with its elemental mapping (placed on an Au substrate). (c) XRD and (d) Raman spectra of the NBs.

To understand the crystallographic properties and the chemical composition, we conducted X-ray diffraction (XRD) and single-particle Raman spectroscopy, as illustrated in Figure 1c and 1d, respectively. The indexed peaks in the XRD spectrum correspond to Bi₂Se₃ along with the background of sapphire (at ~42.16°, see SI for more details).^{53–58} The Raman spectrum (Figure 1d)

displays three characteristic peaks at ~72, ~132 and ~173 cm⁻¹, corresponding respectively to the A_{1g}^1, E_g^2 and A_{1g}^2 modes of Bi₂Se₃.⁵⁹⁻⁶¹

SEM and atomic force microscopy (AFM) (see Figure S1 in SI) analysis indicated that the crosssection dimensions of the NBs have widths (w) of $w \sim 700$ nm and heights (h) of approximately h~300 nm, with lengths varying between ~5 µm and ~30 µm. These observations suggest possible MIR Mie-scattering supported by the NBs.⁶² However, a fundamental understanding of the scattering properties of these NBs requires precise knowledge of the Bi₂Se₃ optical constants. To obtain the optical constants, we performed spectroscopic reflection measurements (FTIR spectroscopy) on flakes of exfoliated Bi₂Se₃ of varying thicknesses, placed on Au substrate (see Figure S2 for a typical spectrum for a flake of thickness ~485 nm and corresponding AFM measurements in Figure S3). To analyze the experimental data and extract the dielectric function and complex RI of Bi₂Se₃, we used RefFIT program⁶³ in which a combination of Drude-Lorentz oscillators were used to model the material response. This fitted curve is based on modeling the material properties with two Lorentz oscillators for the bulk response and one Drude oscillator to account for the topological metallic surface, which was then used to extract the complex RI (Figure 2a). All model parameters are summarized in table 1 of the SI. Figure 2a presents the extracted real and imaginary parts of the complex RI ($\tilde{n} = n + ik$). The dispersion is characterized by very high index values peaking at $n \sim 6.42$ for $\lambda \sim 2.56 \,\mu\text{m}$, which can be attributed to the strong dielectric polarizability of the bulk. This is followed by a Drude-like descent for longer wavelengths, reflecting the combined contribution of both surface metallic states and bulk free carriers resulting from unintentional doping. $^{16,32,64-66}$ These latter effects are also responsible for the losses (k) in the system, which we further examine in the following sections.



Figure 2. Optical properties of Bi₂Se₃ NBs. (a) Derived frequency-dependent complex optical constant of Bi₂Se₃. (b) Pictorial representation of Bi₂Se₃ NB on Au substrate illuminated by a linearly polarized light beam. (c) Comparison of experimentally measured extinction spectrum (black) and calculated FDTD scattering cross-section (red) from a single NB with $w = 0.7 \,\mu\text{m} \& h = 0.3 \,\mu\text{m}$. Inset in (c) depicts the NB cross-section geometric parameters. (d) Cross-sectional view (XY) of the electric (*E*, top) and magnetic (*H*, bottom) field intensities together with their corresponding vector-field profiles at the resonance wavelength of λ =5.99 μ m. White dashed outlines in the figure are guide to the eyes for locating the NB and its interfaces with air and Au substrate.

Nevertheless, the extremely high RI values reported here, originating from the ultra-high permittivity (presented in Figure S4 of SI), are the basis for the ultracompact nanophotonic components presented here.

To investigate the scattering characteristics of the CVD grown Bi₂Se₃ NBs we first used single particle spectroscopy using an FTIR (Nicolet, iS50R) spectrometer coupled to an infrared

microscope (Nicolet, continuum infrared microscope).⁶⁷ Illustration of the illuminated NB on an Au substrate, is depicted in Figure 2b. The experimental spectra shown in Figure 2c, reveals the presence of two pronounced fundamental modes, at $\lambda \sim 4.50$ and $\sim 5.73 \mu$ m, respectively. These results show that the NBs are ultracompact resonators with a dielectric like response within crosssection sizes as small as $\sim \lambda/8$. Finite-Difference Time-Domain (FDTD) simulation (Details on the FDTD simulations can be found in the SI), incorporating the extracted optical constants (Figure 2a) and the NB dimensions, is in good agreement with the experimental results (Figure 2c). Figure 2d shows the electric (*E*, top) and magnetic (*H*, bottom) field profiles of the fundamental resonant mode.⁶⁸ The circulating *H*-field lines as seen in Figure 2d are a signature of a transverse magnetic (TM) resonance.

Figure 3a shows how the experimental unpolarized spectra of the NB can be decomposed into the two orthogonal resonant modes. This was done by inserting a polarizer into the incident beam path and selectively exciting either TE modes, where the *E*-field is perpendicular to the NB long-axis, or TM modes, where the *E*-field is parallel to the NB long-axis (see schematic at the top of Figure 3a). The unpolarized extinction spectrum is thus dominated by two modes, i.e., TE₀ (λ ~ 4.50 µm) and TM₁ (λ ~5.73 µm), as seen in Figure 3a.⁶² The geometric dispersion of the NBs is presented in Figures 3b and 3c, illustrating size dependencies of the resonant modes along a range of infrared wavelengths. In both cases the expected resonance red-shift with increasing size is observed (Figure S5, SI), allowing to engineer the scattering properties of the NBs. The very high index of Bi₂Se₃ enables the support of resonant modes in ultrathin NBs. Figure 3b shows that even a 100nm thick NB supports the TM₁ mode at λ ~2.8µm, while the higher order mode has a modal cutoff for *h*~200nm at λ ~1.5µm. When the height is fixed to *h*=300nm (Figure 3c), both the TM₁ and higher order modes are supported (within the width range, 0.3 μ m < w <0.7 μ m) throughout the studied spectral range 1.5-8.0 μ m.



Figure 3. Polarized and size-dependent behavior of the NBs. (a) TE (blue) and TM (red) polarized scattering of the NB ($w = 0.7 \,\mu\text{m} \& h = 0.3 \,\mu\text{m}$), along with the unpolarized (black) spectra. The top sketch illustrates the orientation of the TE and TM polarizations with respect to NB long-axis. (b, c) FDTD simulated modal evolution as a function of (b) height, *h* (for fixed $w = 0.7 \,\mu\text{m}$) and (c) width, *w* (for fixed $h = 0.3 \,\mu\text{m}$) variation. Color bar on the top indicates intensity of the resonant modes.

Altogether, this size-dependent modal behavior demonstrates how the very high index of Bi₂Se₃ facilitates resonant modes in subwavelength dimensions.

To gain more fundamental understating of the resonant nanostructures, we studied the near-field optical response and local properties of the Bi_2Se_3 NBs, using a dedicated setup consisting of s-SNOM, with an AFM tip as the near-field probe. The AFM probe and the optical apparatus are illustrated respectively in Figures 4a and 4b.



Figure 4. s-SNOM imaging and nanospectroscopy of Bi_2Se_2 NBs. (a) Illustration of near-field probing and consequent scattering from the Bi_2Se_3 NB placed on an Au substrate. (b) Schematic illustration of the s-SNOM setup with the heterodyne detection. BS refers to beam-splitter and MCT refers to Mercury-Cadmium-Telluride detector (c) Hyperspectral image, exhibiting mode evolution across the NB width. (d) Near-field scattered optical amplitude (s₃) and the corresponding phase (φ_3) from the NB.

s-SNOM based nanoscopy is a powerful technique for characterizing nanophotonic systems, material identification and probing exotic nanoscale and quantum phenomenon with 10-20 nm spatial resolution.^{39,69–78} This technique allows to gather local information that is either lost or averaged out in the far-field response, as well to couple into excitations which are difficult to access from the far-field. In this study, we used a commercial s-SNOM (Neaspec, Attocube)

configured with an asymmetric Michelson interferometer and a broadband MIR illuminating source (Figure 4b). More details of s-SNOM measurement and set-up can be found in the SI. Hyperspectral broadband nanospectrocopy measurements shown in Figure 4c, performed along the NB cross-section (w), exhibit a prominent resonant dip around $\lambda \sim 5.65 \mu m$, which is consistently fixed along each scan position of the NB width. This measurement provided information on the nature of the spatial mode evolution, illustrating pinning of the resonant mode at the same spectral position ($\lambda \sim 5.65 \mu m$) with a minuscule deviation of $\sim 4\%$ across a scan length of ~650 nm. These results suggest that the NB was grown with a high spatial uniformity. We also note that due to the nature of the z-oriented AFM probe, the near-field excitation (and collection) has a dominant E-field along the z-axis, which can explain the small discrepancy between the farfield TM₁ mode observed at $\lambda \sim 5.73 \,\mu\text{m}$ and the mode excited by the near field probe ($\lambda \sim 5.65 \,\mu\text{m}$). Local amplitude and phase scans, facilitated by the heterodyne detection configuration, reveal reflection phase shifts of up to 2π across the resonance wavelength, as seen in Figure 4d. Achieving 2π phase shifts (Figure 4d) is fundamental in nanophotonics and meta-optic design^{68,79–83} and demonstrates the potential of Bi₂Se₃ in these fields. However, although the location of the resonance mode across the NB width and length, was consistently measured at $\lambda \sim 5.65 \mu m$, mapping of the corresponding local reflection phase, revealed significant variations from the 2π phase shift presented in Figure 4d. In the following, we exemplify the capabilities of near-field microscopy to locally probe variations in the optical constants in different domains along the NBvariations which are otherwise averaged out in the far-field.

Figures 5a-c present experimental local phase measurements at three different domains along the NB, demonstrating the difference between three typically observed phases of $\varphi \sim 0.37\pi$ and $\varphi \sim 0.72\pi$ radians (Figure 5a and 5b) and the maximum measured phase shift of φ

 $\sim 2\pi$ radians (Figure 5c). In a typical scattering scenario, an optical phase shift of π radians is observed across a single scattering resonance.⁸⁵ However, proper engineering schemes can be adopted to obtain a full 2π phase shift.^{86,87} One such approach, as implemented in this study (NB on an Au substate), is to place a resonator over a metal substrate, and if small or negligible ohmic losses exist in the system, this will result in a maximum of 2π phase shift.⁸⁷ due to the interference of the resonating mode with its mirror image in the substrate.^{68,88} However, if ohmic losses exist in the system, then the maximum phase shift is not guaranteed. Physically, the imaginary part of the refractive index *k*, not only determines the losses in the material, but it also governs important resonator parameters such as light localization, quality-factor, and the optical phase shift. As we show here, even a small change in *k*, can lead to significant changes in the reflected phase from the NB resonator.

To understand the origin of these phase variations, we conducted a series of FDTD reflection phase simulations⁸⁴ (details on FDTD simulation can be found in the SI), for three different cases, as presented in Figures 5d-f. The reflected phase (φ) in Figure 5d was calculated using the experimentally extracted optical constants (Figure 2a), where *k* ~0.39 (at wavelengths around the resonance wavelength) and is in excellent agreement with the experimentally observed reflected phase shift seen in Figure 5a. In Figures 5e and 5f we modified the optical constants to obtain slightly smaller *k*-values of *k*=0.25 (Figure 5e) and *k*=0.20 (Figure 5f), respectively, which provide excellent matches to the experimentally observed phase shifts (Figure 5b and 5c). However, the resulting reflection phase shifts are dramatically different in all the three cases. For the experimentally extracted index values (*k* ~0.39), the corresponding phase shift is $\varphi ~0.37\pi$, whereas it is doubled ($\varphi ~0.72\pi$) for *k* = 0.25 and abruptly jumps to values near $\varphi ~2\pi$ for *k* = 0.2.

To make sure these local phase variations are not caused by random local imperfections or variations in NB dimensions, we measured the phase across the NB length. Figure 5g shows an experimentally obtained phase map for a continuous line scan of ~1 μ m (uncertainty in height is ~1.7 nm) along the NB long axis. From this scan we observe that a relatively constant phase shift of ~0.37 π is obtained within this domain, in accordance with the simulated phase shift using the experimentally derived optical constants. This measurement further supports that the NB is homogeneous in terms of physical dimensions and geometry. Figure 5h on the other hand shows the calculated reflection phase for a continuous scan over the *k*-values (while the real part *n* is kept fixed). The abrupt jump in the reflection phase shift around *k* ~0.2 is evident. This point corresponds to the critical losses in the system in terms of phase pickup, and if these losses are kept below this value – a near 2π shift can be reached. SI Figure S6 shows that this specific critical *k*_{cr} ~0.2 value is linked to the real part of the refractive index *n*, so that (*k*/*n*)_{cr} is the normalized critical loss value, where in our case *n*~6 and (*k*/*n*)_{cr}~0.033.

Analyzing the experimental local phase observations in Figures 5a-c, in the context of these calculations (Figures 5d-g), we can infer that local variations in the optical constants of the NB exist, and more specifically in the imaginary RI, k-value. It should be noted that since we do not observe any notable shift in the resonance wavelength, variations in the real part of the index (n) cannot be the reason for this large change in the local phase, as we further demonstrate in the SI (Figures S7 and S8). Another factor that can critically cause these dramatic phase shift swings is the local variations in the NB geometric dimensions, i.e., h and w. As we show in the SI (Figure S9), even large variations in the width or height of up to 33% in the NB, cannot account for the large observed phase shifts. After excluding the possibilities of spatial variations in the real part of the RI (n) and geometric heterogeneities as potential mechanisms for the experimentally

observed large phase shifts, we can thus deduce that local variations in the imaginary part of the RI (k) are the most likely reason for these significant fluctuations. Possible physical mechanisms behind these local k variations may include inhomogeneity in sample defects, bulk carrier concentration and the so-called "*aging-effect*" in TIs, an effect arising from changes in electronic structure of surface states with time.^{64,89} In Bi₂Se₃, this effect is quite prominent and arises primarily from unintentional doping, native defects and vacancies.^{64–66,90-92}



Figure 5. (a-c) Experimentally measured near-field amplitude and phase (ϕ) at different NB locations, resulting in a (a) $\phi \sim 0.37\pi$, (b) $\phi \sim 0.72\pi$ and (c) $\phi \sim 2\pi$ optical phase shifts. (d-f) Simulated near-field results with (d) extracted complex optical constants obtained from far-field measurements and varying *k*-values as, (e) *k*=0.25 and (f) *k*=0.20. (g) Optical phase map for a continuous line scan of ~1 µm along the NB long axis. (h) Detailed variation of near-field optical phase shift with varying *k*-values.

Finally, it is noteworthy to mention that NBs with larger dimensions, supporting resonances at longer wavelengths ($\lambda \ge 7.44 \mu m$), would always exhibit a near- 2π optical phase shift (see Figure S10 in SI). This response arises from the combined effect of larger NB dimensions (a higher Q-factor) and lower obtained *k*-values in the longwave IR regime (see Figure 2a).

Regardless, the experimentally measured 2π phase shifts observed in large domains of the samples suggest that Bi₂Se₃ within these areas exhibit low losses and demonstrate the power of TIs as a high index material for ultracompact nanophotonics. Furthermore, these local areas of minimal loss demonstrate the potential to obtain improved optical properties in TIs using advanced and optimized growth and fabrication techniques, potentially catalyzing further research into the underlying mechanisms. The near-field investigations conducted in this study illuminate a more intricate view of the spatially varying optical characteristics of the Bi₂Se₃ NB at the nanoscale, an information crucial for designing nanoscale photonic devices.

To summarize, in this work we demonstrate the synthesis of Bi₂Se₃ TI NBs of varying aspect ratios, using a CVD technique. Investigations on the optical properties revealed that the NBs are Mie-resonant nanostructures supporting both TE and TM polarized resonances, with very high RI values culminating in $n \sim 6.42$ and low extinction coefficient values, within a wide range of MIR wavelengths. Near field phase mapping probed by s-SNOM, revealed local reflection phase shifts of up to 2π , across the resonance. These local near field phase shift variations can be explained by small changes in the imaginary part of the index k, within different domains of the NB. The current study highlights the field of TI metaphotonics and demonstrates the potential of these highindex TI NBs for quantum circuitry, non-linear generation, high Q-factor metasurfaces, IR photodetection and many more.

Acknowledgements

We would like to thank the Israel Science Foundation (ISF) for funding this work under grant no.

2110/19.

References

- (1) Hasan, M. Z.; Kane, C. L. Colloquium: Topological Insulators. *Rev. Mod. Phys.* **2010**, *82* (4), 3045–3067. https://doi.org/10.1103/RevModPhys.82.3045.
- (2) Haldane, F. D. M. Nobel Lecture: Topological Quantum Matter. *Rev. Mod. Phys.* 2017, 89 (4), 040502. https://doi.org/10.1103/RevModPhys.89.040502.
- (3) Moore, J. E. The Birth of Topological Insulators. *Nature* **2010**, 464 (7286), 194–198. https://doi.org/10.1038/nature08916.
- Qi, X.-L.; Zhang, S.-C. Topological Insulators and Superconductors. *Rev. Mod. Phys.* 2011, 83 (4), 1057–1110. https://doi.org/10.1103/RevModPhys.83.1057.
- (5) Ando, Y. Topological Insulator Materials. J. Phys. Soc. Japan 2013, 82 (10), 1–32. https://doi.org/10.7566/JPSJ.82.102001.
- (6) König, M.; Wiedmann, S.; Brüne, C.; Roth, A.; Buhmann, H.; Molenkamp, L. W.; Qi, X.-L.; Zhang, S.-C. Quantum Spin Hall Insulator State in HgTe Quantum Wells. *Science* 2007, *318* (5851), 766–770. https://doi.org/10.1126/science.1148047.
- (7) Brüne, C.; Liu, C. X.; Novik, E. G.; Hankiewicz, E. M.; Buhmann, H.; Chen, Y. L.; Qi, X. L.; Shen, Z. X.; Zhang, S. C.; Molenkamp, L. W. Quantum Hall Effect from the Topological Surface States of Strained Bulk HgTe. *Phys. Rev. Lett.* **2011**, *106* (12), 1–4. https://doi.org/10.1103/PhysRevLett.106.126803.
- (8) Hamdou, B.; Gooth, J.; Dorn, A.; Pippel, E.; Nielsch, K. Aharonov-Bohm oscillations and weak antilocalization in topological insulator Sb₂Te₃ nanowires. *Appl. Phys. Lett.* **2013**, *102* (22), 223110. https://doi.org/10.1063/1.4809826.
- (9) Zhang, H.; Liu, C.-X.; Qi, X.-L.; Dai, X.; Fang, Z.; Zhang, S.-C. Topological Insulators in Bi₂Se₃, Bi₂Te₃ and Sb₂Te₃ with a Single Dirac Cone on the Surface. *Nat. Phys.* **2009**, *5* (6), 438–442. https://doi.org/10.1038/nphys1270.
- (10) Taguchi, T.; Ikeda, M.; Li, H.; Suzuki, A.; Yang, X.; Ishii, H.; Liao, Y.-F.; Ota, H.; Goto, H.; Eguchi, R.; Kubozono, Y. Superconductivity of Topological Insulator Sb₂Te_{3-y}Se_y under Pressure . J. Phys. Condens. Matter 2021, 33 (48), 485704. https://doi.org/10.1088/1361-648x/ac244b.
- (11) Kumar, K.; Kumar, Y.; Patnaik, M. S. S.; Awana, I. F. V. P. S. Effect of Magnetic (Nd) Doping on Electrical and Magnetic Properties of Topological - Sb₂Te₃ Single Crystal. *J. Supercond. Nov. Magn.* 2021, 2463–2469. https://doi.org/10.1007/s10948-021-05983-y.
- (12) Peng, H.; Dang, W.; Cao, J.; Chen, Y.; Wu, D.; Zheng, W.; Li, H.; Shen, Z. X.; Liu, Z. Topological Insulator Nanostructures for Near-Infrared Transparent Flexible Electrodes. *Nat. Chem.* 2012, 4 (4), 281–286. https://doi.org/10.1038/nchem.1277.
- (13) Di Pietro, P.; Ortolani, M.; Limaj, O.; Di Gaspare, A.; Giliberti, V.; Giorgianni, F.; Brahlek, M.; Bansal, N.; Koirala, N.; Oh, S.; Calvani, P.; Lupi, S. Observation of Dirac Plasmons in a Topological Insulator. *Nat. Nanotechnol.* **2013**, *8* (8), 556–560. https://doi.org/10.1038/nnano.2013.134.
- (14) Fang, M.; Wang, Z.; Gu, H.; Song, B.; Guo, Z.; Zhu, J.; Chen, X.; Zhang, C.; Jiang, H.; Liu, S. Complex

Optical Conductivity of Bi 2 Se 3 Thin Film: Approaching Two-Dimensional Limit. *Appl. Phys. Lett.* **2021**, *118* (19), 191101. https://doi.org/10.1063/5.0049170.

- (15) Xia, Y.; Qian, D.; Hsieh, D.; Wray, L.; Pal, A.; Lin, H.; Bansil, A.; Grauer, D.; Hor, Y. S.; Cava, R. J.; Hasan, M. Z. Observation of a Large-Gap Topological-Insulator Class with a Single Dirac Cone on the Surface. *Nat. Phys.* 2009, 5 (6), 398–402. https://doi.org/10.1038/nphys1274.
- (16) Krishnamoorthy, H. N. S.; Adamo, G.; Yin, J.; Savinov, V.; Zheludev, N. I.; Soci, C. Infrared Dielectric Metamaterials from High Refractive Index Chalcogenides. *Nat. Commun.* 2020, *11* (1), 1692. https://doi.org/10.1038/s41467-020-15444-0.
- (17) Arakane, T.; Sato, T.; Souma, S.; Kosaka, K.; Nakayama, K.; Komatsu, M.; Takahashi, T.; Ren, Z.; Segawa, K.; Ando, Y. Tunable Dirac Cone in the Topological Insulator Bi_{2-x}Sb_xTe_{3-y}Se_y. *Nat. Commun.* **2012**, *3*. https://doi.org/10.1038/ncomms1639.
- (18) Zhu, T.; Bishop, A. J.; Zhou, T.; Zhu, M.; Ohara, D. J.; Baker, A. A.; Cheng, S.; Walko, R. C.; Repicky, J. J.; Liu, T.; Gupta, J. A.; Jozwiak, C. M.; Rotenberg, E.; Hwang, J.; Žutić, I.; Kawakami, R. K. Synthesis, Magnetic Properties, and Electronic Structure of Magnetic Topological Insulator MnBi₂Se₄. *Nano Lett.* **2021**, *21* (12), 5083–5090. https://doi.org/10.1021/acs.nanolett.1c00141.
- (19) Zhang, P.; Noguchi, R.; Kuroda, K.; Lin, C.; Kawaguchi, K.; Yaji, K.; Harasawa, A.; Lippmaa, M.; Nie, S.; Weng, H.; Kandyba, V.; Giampietri, A.; Barinov, A.; Li, Q.; Gu, G. D.; Shin, S.; Kondo, T. Observation and Control of the Weak Topological Insulator State in ZrTe₅. *Nat. Commun.* **2021**, *12* (1), 6–12. https://doi.org/10.1038/s41467-020-20564-8.
- (20) Gilbert, M. J. Topological Electronics. *Commun. Phys.* **2021**, *4* (1), 70. https://doi.org/10.1038/s42005-021-00569-5.
- (21) Cho, S.; Butch, N. P.; Paglione, J.; Fuhrer, M. S. Insulating Behavior in Ultrathin Bismuth Selenide Field Effect Transistors. *Nano Lett.* **2011**, *11* (5), 1925–1927. https://doi.org/10.1021/nl200017f.
- (22) Raghu, S.; Haldane, F. D. M. Analogs of Quantum-Hall-Effect Edge States in Photonic Crystals. *Phys. Rev.* A 2008, 78 (3), 033834. https://doi.org/10.1103/PhysRevA.78.033834.
- (23) Haldane, F. D. M.; Raghu, S. Possible Realization of Directional Optical Waveguides in Photonic Crystals with Broken Time-Reversal Symmetry. *Phys. Rev. Lett.* **2008**, *100* (1), 1–4. https://doi.org/10.1103/PhysRevLett.100.013904.
- (24) Dikopoltsev, A.; Harder, T. H.; Lustig, E.; Egorov, O. A.; Beierlein, J.; Wolf, A.; Lumer, Y.; Emmerling, M.; Schneider, C.; Höfling, S.; Segev, M.; Klembt, S. Topological Insulator Vertical-Cavity Laser Array. *Science* 2021, 373 (6562), 1514–1517. https://doi.org/10.1126/science.abj2232.
- (25) Lu, L.; Joannopoulos, J. D.; Soljačić, M. Topological Photonics. *Nat. Photonics* **2014**, 8 (11), 821–829. https://doi.org/10.1038/nphoton.2014.248.
- (26) Alù, A.; Pilozzi, L.; Xu, H.; Fan, J. Topological Photonics and beyond: Introduction. *Photonics Res.* 2021, 9 (1), TPB1. https://doi.org/10.1364/prj.415860.
- (27) Ozawa, T.; Price, H. M.; Amo, A.; Goldman, N.; Hafezi, M.; Lu, L.; Rechtsman, M. C.; Schuster, D.; Simon, J.; Zilberberg, O.; Carusotto, I. Topological Photonics. *Rev. Mod. Phys.* 2019, *91* (1), 15006. https://doi.org/10.1103/RevModPhys.91.015006.
- (28) Segev, M.; Bandres, M. A. Topological Photonics: Where Do We Go from Here? *Nanophotonics* **2020**, *10* (1), 425–434. https://doi.org/10.1515/nanoph-2020-0441.
- (29) Schmid, C. P.; Weigl, L.; Grössing, P.; Junk, V.; Gorini, C.; Schlauderer, S.; Ito, S.; Meierhofer, M.; Hofmann, N.; Afanasiev, D.; Crewse, J.; Kokh, K. A.; Tereshchenko, O. E.; Güdde, J.; Evers, F.; Wilhelm, J.; Richter, K.; Höfer, U.; Huber, R. Tunable Non-Integer High-Harmonic Generation in a Topological Insulator. *Nature* 2021, *593* (7859), 385–390. https://doi.org/10.1038/s41586-021-03466-7.
- (30) Politano, A.; Viti, L.; Vitiello, M. S. Optoelectronic Devices, Plasmonics, and Photonics with Topological

Insulators. APL Mater. 2017, 5 (3). https://doi.org/10.1063/1.4977782.

- (31) Greenaway, D. L.; Harbeke, G. Band Structure of Bismuth Telluride, Bismuth Selenide and Their Respective Alloys. J. Phys. Chem. Solids **1965**, 26 (10), 1585–1604. https://doi.org/10.1016/0022-3697(65)90092-2.
- (32) Singh, D.; Nandi, S.; Fleger, Y.; Cohen, S. Z.; Lewi, T. Deep-Subwavelength Resonant Meta-Optics Enabled by Ultra-High Index Topological Insulators. *Laser Photonics Rev.* 2023, 2200841. https://doi.org/10.1002/lpor.202200841
- (33) Yue, Z.; Cai, B.; Wang, L.; Wang, X.; Gu, M. Intrinsically Core-Shell Plasmonic Dielectric Nanostructures with Ultrahigh Refractive Index. *Sci. Adv.* **2016**, *2* (3). https://doi.org/10.1126/sciadv.1501536.
- (34) Esslinger, M.; Vogelgesang, R.; Talebi, N.; Khunsin, W.; Gehring, P.; de Zuani, S.; Gompf, B.; Kern, K. Tetradymites as Natural Hyperbolic Materials for the Near-Infrared to Visible. ACS Photonics 2014, 1 (12), 1285–1289. https://doi.org/10.1021/ph500296e.
- (35) Heide, C.; Kobayashi, Y.; Baykusheva, D. R.; Jain, D.; Sobota, J. A.; Hashimoto, M.; Kirchmann, P. S.; Oh, S.; Heinz, T. F.; Reis, D. A.; Ghimire, S. Probing Topological Phase Transitions Using High-Harmonic Generation. *Nat. Photonics* 2022, *16* (9), 620–624. https://doi.org/10.1038/s41566-022-01050-7.
- (36) Stockman, M. I.; Kneipp, K.; Bozhevolnyi, S. I.; Saha, S.; Dutta, A.; Ndukaife, J.; Kinsey, N.; Reddy, H.; Guler, U.; Shalaev, V. M.; Boltasseva, A.; Gholipour, B.; Krishnamoorthy, H. N. S.; MacDonald, K. F.; Soci, C.; Zheludev, N. I.; Savinov, V.; Singh, R.; Groß, P.; Lienau, C.; Vadai, M.; Solomon, M. L.; Barton, D. R.; Lawrence, M.; Dionne, J. A.; Boriskina, S. V.; Esteban, R.; Aizpurua, J.; Zhang, X.; Yang, S.; Wang, D.; Wang, W.; Odom, T. W.; Accanto, N.; de Roque, P. M.; Hancu, I. M.; Piatkowski, L.; van Hulst, N. F.; Kling, M. F. Roadmap on Plasmonics. J. Opt. 2018, 20 (4), 043001. https://doi.org/10.1088/2040-8986/aaa114.
- (37) Ou, J.-Y.; So, J.-K.; Adamo, G.; Sulaev, A.; Wang, L.; Zheludev, N. I. Ultraviolet and Visible Range Plasmonics in the Topological Insulator Bi_{1.5}Sb_{0.5}Te_{1.8}Se_{1.2}. *Nat. Commun.* **2014**, *5* (1), 5139. https://doi.org/10.1038/ncomms6139.
- (38) Autore, M.; D'Apuzzo, F.; Di Gaspare, A.; Giliberti, V.; Limaj, O.; Roy, P.; Brahlek, M.; Koirala, N.; Oh, S.; García de Abajo, F. J.; Lupi, S. Plasmon-Phonon Interactions in Topological Insulator Microrings. Adv. Opt. Mater. 2015, 3 (9), 1257–1263. https://doi.org/10.1002/adom.201400513.
- (39) Dubrovkin, A. M.; Adamo, G.; Yin, J.; Wang, L.; Soci, C.; Wang, Q. J.; Zheludev, N. I. Visible Range Plasmonic Modes on Topological Insulator Nanostructures. *Adv. Opt. Mater.* 2017, 5 (3), 1600768. https://doi.org/10.1002/adom.201600768.
- (40) Sun, X.; Adamo, G.; Eginligil, M.; Krishnamoorthy, H. N. S.; Zheludev, N. I.; Soci, C. Topological Insulator Metamaterial with Giant Circular Photogalvanic Effect. *Sci. Adv.* 2021, 7 (14), 1–8. https://doi.org/10.1126/sciadv.abe5748.
- (41) McIver, J. W.; Hsieh, D.; Steinberg, H.; Jarillo-Herrero, P.; Gedik, N. Control over Topological Insulator Photocurrents with Light Polarization. *Nat. Nanotechnol.* 2012, 7 (2), 96–100. https://doi.org/10.1038/nnano.2011.214.
- (42) Pesin, D.; MacDonald, A. H. Spintronics and Pseudospintronics in Graphene and Topological Insulators. *Nat. Mater.* **2012**, *11* (5), 409–416. https://doi.org/10.1038/nmat3305.
- (43) Black, J.; Conwell, E. M.; Seigle, L.; Spencer, C. W. Electrical and Optical Properties of Some M₂^{V-B}N₃^{VI-B} Semiconductors. J. Phys. Chem. Solids 1957, 2, 240–251. https://doi.org/10.1016/0022-3697(57)90090-2.
- (44) Kim, D.-K.; Hong, S.-B.; Kim, J.; Cho, M.-H. Topological insulator bismuth selenide grown on black phosphorus for sensitive broadband photodetection. *J. Mater. Chem. C* **2021**, 9, 15150–15157. https://doi.org/10.1039/D1TC02613E.
- (45) Whitcher, T. J.; Silly, M. G.; Yang, M.; Das, P. K.; Peyrot, D.; Chi, X.; Eddrief, M.; Moon, J.; Oh, S.; Castro-Neto, A. H.; Breese, M. B. H.; Wee, A. T. S.; Silly, F.; Rusydi, A. Correlated Plasmons in the Topological Insulator Bi₂Se₃ Induced by Long-Range Electron Correlations. *NPG Asia Mater.* **2020**, *12* (1), 37.

https://doi.org/10.1038/s41427-020-0218-7.

- (46) Fang, M.; Wang, Z.; Gu, H.; Tong, M.; Song, B.; Xie, X.; Zhou, T.; Chen, X.; Jiang, H.; Jiang, T.; Liu, S. Layer-Dependent Dielectric Permittivity of Topological Insulator Bi₂Se₃ Thin Films. *Appl. Surf. Sci.* 2020, 509. https://doi.org/10.1016/j.apsusc.2019.144822.
- (47) Mazumder, K.; Shirage, P. M. A Brief Review of Bi₂Se₃ Based Topological Insulator: From Fundamentals to Applications. J. Alloys Compd. 2021, 888, 161492. https://doi.org/10.1016/j.jallcom.2021.161492.
- (48) Wang, F. K.; Yang, S. J.; Zhai, T. Y. 2D Bi2Se3 Materials for Optoelectronics. *iScience* **2021**, *24* (11), 103291. https://doi.org/10.1016/j.isci.2021.103291.
- (49) Lawal, A.; Shaari, A.; Ahmed, R.; Jarkoni, N. First-Principles Many-Body Comparative Study of Bi₂Se₃ Crystal: A Promising Candidate for Broadband Photodetector. *Phys. Lett. A* 2017, *381* (35), 2993–2999. https://doi.org/10.1016/j.physleta.2017.07.023.
- (50) Liu, Y.; Cao, L.; Zhong, J.; Yu, J.; He, J.; Liu, Z. Synthesis of Bismuth Selenide Nanoplates by Solvothermal Methods and Its Stacking Optical Properties. *J. Appl. Phys.* **2019**, *125* (3). https://doi.org/10.1063/1.5063609.
- (51) Cho, H. D.; Lee, J.; Kim, D. Y.; Chung, S. Y.; Lee, J.-K. Enhanced Photoresponse of High Crystalline Bi₂Se₃ Thin-Films Using Patterned Substrates. *ACS Appl. Mater. Interfaces* **2023**, *15* (18), 22274–22281. https://doi.org/10.1021/acsami.3c02501.
- (52) Kim, J.; Park, S.; Jang, H.; Koirala, N.; Lee, J.-B.; Kim, U. J.; Lee, H.-S.; Roh, Y.-G.; Lee, H.; Sim, S.; Cha, S.; In, C.; Park, J.; Lee, J.; Noh, M.; Moon, J.; Salehi, M.; Sung, J.; Chee, S.-S.; Ham, M.-H.; Jo, M.-H.; Oh, S.; Ahn, J.-H.; Hwang, S. W.; Kim, D.; Choi, H. Highly Sensitive, Gate-Tunable, Room-Temperature Mid-Infrared Photodetection Based on Graphene–Bi₂Se₃ Heterostructure. *ACS Photonics* **2017**, *4* (3), 482–488. https://doi.org/10.1021/acsphotonics.6b00972.
- (53) Song, Z.; Chang, Y.; Xie, H.; Yu, X.-F.; Chu, P. K.; Chen, T. Decorated Ultrathin Bismuth Selenide Nanosheets as Targeted Theranostic Agents for in Vivo Imaging Guided Cancer Radiation Therapy. NPG Asia Mater. 2017, 9 (10), e439. https://doi.org/10.1038/am.2017.167.
- (54) Kulsi, C.; Ghosh, A.; Mondal, A.; Kargupta, K.; Ganguly, S.; Banerjee, D. Remarkable Photo-Catalytic Degradation of Malachite Green by Nickel Doped Bismuth Selenide under Visible Light Irradiation. *Appl. Surf. Sci.* 2017, 392, 540–548. https://doi.org/10.1016/j.apsusc.2016.09.063.
- (55) Xiao-Yong, G.; Song-You, W.; Jing, L.; Yu-Xiang, Z.; Rong-Jun, Z.; Peng, Z.; Yue-Mei, Y.; Liang-Yao, C. Structural and Optical Investigation of GaN Grown by Metal-Organic Chemical Vapor Deposition. J. Korean Phys. Soc. 2004, 44 (3), 765. https://doi.org/10.3938/jkps.44.765.
- (56) Kadel, K.; Kumari, L.; Li, W.; Huang, J.; Provencio, P. Synthesis and Thermoelectric Properties of Bi₂Se₃ Nanostructures. *Nanoscale Res.Lett.* **2011**,6, 57. https://doi.org/10.1007/s11671-010-9795-7.
- (57) Yang, X.; Wang, X.; Zhang, Z. Synthesis and Optical Properties of Single-Crystalline Bismuth Selenide Nanorods via a Convenient Route. J. Cryst. Growth 2005, 276 (3–4), 566–570. https://doi.org/10.1016/j.jcrysgro.2004.11.422.
- (58) Xu, S.; Zhao, W.; Hong, J.-M.; Zhu, J.-J.; Chen, H.-Y. Photochemical Synthesis of Bi₂Se₃ Nanosphere and Nanorods. *Mater. Lett.* **2005**, *59* (2–3), 319–321. https://doi.org/10.1016/j.matlet.2004.10.011.
- (59) Zhang, J.; Peng, Z.; Soni, A.; Zhao, Y.; Xiong, Y.; Peng, B.; Wang, J.; Dresselhaus, M. S.; Xiong, Q. Raman Spectroscopy of Few-Quintuple Layer Topological Insulator Bi₂Se₃ Nanoplatelets. *Nano Lett.* 2011, *11* (6), 2407–2414. https://doi.org/10.1021/nl200773n.
- (60) Sapkota, Y. R.; Alkabsh, A.; Walber, A.; Samassekou, H.; Mazumdar, D. Optical Evidence for Blue Shift in Topological Insulator Bismuth Selenide in the Few-Layer Limit. *Appl. Phys. Lett.* 2017, *110* (18). https://doi.org/10.1063/1.4982631.
- (61) Chen, X.; Tang, H.; Huang, Z.; Zhou, J.; Ren, X.; Huang, K.; Qi, X.; Zhong, J. Flexible Bismuth Selenide /Graphene Composite Paper for Lithium-Ion Batteries. *Ceram. Int.* **2017**, *43* (1), 1437–1442.

https://doi.org/10.1016/j.ceramint.2016.10.110.

- (62) Schuller, J. A.; Zia, R.; Taubner, T.; Brongersma, M. L. Dielectric Metamaterials Based on Electric and Magnetic Resonances of Silicon Carbide Particles. *Phys. Rev. Lett.* 2007, 99 (10), 1–4. https://doi.org/10.1103/PhysRevLett.99.107401.
- Kuzmenko, A. B. Kramers–Kronig Constrained Variational Analysis of Optical Spectra. *Rev. Sci. Instrum.* 2005, 76 (8), 083108. https://doi.org/10.1063/1.1979470.
- (64) Shirodkar, S. N.; Stephen, G. M.; Hanbicki, A. T.; Friedman, A. L.; Dev, P. Healing Se Vacancies in Bi₂Se₃ by Ambient Gases. J. Phys. Chem. C **2022**, 126 (39), 16877–16884. https://doi.org/10.1021/acs.jpcc.2c05175.
- Walsh, L. A.; Green, A. J.; Addou, R.; Nolting, W.; Cormier, C. R.; Barton, A. T.; Mowll, T. R.; Yue, R.; Lu, N.; Kim, J.; Kim, M. J.; LaBella, V. P.; Ventrice, C. A.; McDonnell, S.; Vandenberghe, W. G.; Wallace, R. M.; Diebold, A.; Hinkle, C. L. Fermi Level Manipulation through Native Doping in the Topological Insulator Bi 2 Se 3. ACS Nano 2018, 12 (6), 6310–6318. https://doi.org/10.1021/acsnano.8b03414.
- (66) Jafarpisheh, S.; Ju, A.; Janßen, K.; Taniguchi, T.; Watanabe, K.; Stampfer, C.; Beschoten, B. Reducing the Impact of Bulk Doping on Transport Properties of Bi-Based 3D Topological Insulators. *Phys. status solidi* 2021, 258 (1), 2000021. https://doi.org/10.1002/pssb.202000021.
- (67) Singh, D.; Poplinger, M.; Twitto, A.; Snitkoff, R.; Nanikashvili, P.; Azolay, O.; Levi, A.; Stern, C.; Taguri, G. C.; Albo, A.; Naveh, D.; Lewi, T. Chemical Vapor Deposition of Spherical Amorphous Selenium Mie Resonators for Infrared Meta-Optics. ACS Appl. Mater. Interfaces 2022, 14 (3), 4612–4619. https://doi.org/10.1021/acsami.1c17812.
- (68) Iyer, P. P.; Pendharkar, M.; Schuller, J. A. Electrically Reconfigurable Metasurfaces Using Heterojunction Resonators. *Adv. Opt. Mater.* **2016**, *4* (10), 1582–1588. https://doi.org/10.1002/adom.201600297.
- (69) Chen, S.; Leng, P. L.; Konečná, A.; Modin, E.; Gutierrez-Amigo, M.; Vicentini, E.; Martín-García, B.; Barra-Burillo, M.; Niehues, I.; Maciel Escudero, C.; Xie, X. Y.; Hueso, L. E.; Artacho, E.; Aizpurua, J.; Errea, I.; Vergniory, M. G.; Chuvilin, A.; Xiu, F. X.; Hillenbrand, R. Real-Space Observation of Ultraconfined in-Plane Anisotropic Acoustic Terahertz Plasmon Polaritons. *Nat. Mater.* **2023**, *22* (7), 860–866. https://doi.org/10.1038/s41563-023-01547-8.
- Qazilbash, M. M.; Brehm, M.; Chae, B.-G.; Ho, P.-C.; Andreev, G. O.; Kim, B.-J.; Yun, S. J.; Balatsky, A. V.; Maple, M. B.; Keilmann, F.; Kim, H.-T.; Basov, D. N. Mott Transition in VO₂ Revealed by Infrared Spectroscopy and Nano-Imaging. *Science* 2007, 318 (5857), 1750–1753. https://doi.org/10.1126/science.1150124.
- (71) Chen, J.; Badioli, M.; Alonso-González, P.; Thongrattanasiri, S.; Huth, F.; Osmond, J.; Spasenović, M.; Centeno, A.; Pesquera, A.; Godignon, P.; Zurutuza Elorza, A.; Camara, N.; de Abajo, F. J. G.; Hillenbrand, R.; Koppens, F. H. L. Optical Nano-Imaging of Gate-Tunable Graphene Plasmons. *Nature* 2012, 487 (7405), 77–81. https://doi.org/10.1038/nature11254.
- (72) Zhang, L. M.; Andreev, G. O.; Fei, Z.; McLeod, A. S.; Dominguez, G.; Thiemens, M.; Castro-Neto, A. H.; Basov, D. N.; Fogler, M. M. Near-Field Spectroscopy of Silicon Dioxide Thin Films. *Phys. Rev. B* 2012, 85 (7), 075419. https://doi.org/10.1103/PhysRevB.85.075419.
- (73) Hillenbrand, R.; Taubner, T.; Keilmann, F. Phonon-Enhanced Light-Matter Interaction at the Nanometre Scale. *Nature* **2002**, 418, 159–162. https://doi.org/10.1038/nature00899.
- (74) Huth, F.; Govyadinov, A.; Amarie, S.; Nuansing, W.; Keilmann, F.; Hillenbrand, R. Nano-FTIR Absorption Spectroscopy of Molecular Fingerprints at 20 Nm Spatial Resolution. *Nano Lett.* 2012, *12* (8), 3973–3978. https://doi.org/10.1021/nl301159v.
- (75) Huber, A. J.; Ziegler, A.; Köck, T.; Hillenbrand, R. Infrared Nanoscopy of Strained Semiconductors. *Nat. Nanotechnol.* **2009**, *4* (3), 153–157. https://doi.org/10.1038/nnano.2008.399.
- (76) Taubner, T.; Hillenbrand, R.; Keilmann, F. Nanoscale Polymer Recognition by Spectral Signature in

Scattering Infrared Near-Field Microscopy. *Appl. Phys. Lett.* **2004**, *85* (21), 5064–5066. https://doi.org/10.1063/1.1827334.

- (77) Huber, A. J.; Ocelic, N.; Hillenbrand, R. Local Excitation and Interference of Surface Phonon Polaritons Studied by Near-Field Infrared Microscopy. J. Microsc. 2008, 229 (3), 389–395. https://doi.org/10.1111/j.1365-2818.2008.01917.x.
- Guo, X.; He, X.; Degnan, Z.; Chiu, C.-C.; Donose, B. D.; Bertling, K.; Fedorov, A.; Rakic, A. D.; Jacobson, P. Terahertz nanospectroscopy of plasmon polaritons for the evaluation of doping in quantum devices. *Nanophotonics* 2023, *12* (10), 1865–1875. https://doi.org/10.1515/nanoph-2023-0064.
- (79) Li, J.; Wu, T.; Xu, W.; Liu, Y.; Liu, C.; Wang, Y.; Yu, Z.; Zhu, D.; Yu, L.; Ye, H. Mechanisms of 2π Phase Control in Dielectric Metasurface and Transmission Enhancement Effect. *Opt. Express* 2019, 27 (16), 23186. https://doi.org/10.1364/oe.27.023186.
- (80) Thureja, P.; Shirmanesh, G. K.; Fountaine, K. T.; Sokhoyan, R.; Grajower, M.; Atwater, H. A. Array-Level Inverse Design of Beam Steering Active Metasurfaces. ACS Nano 2020, 14 (11), 15042–15055. https://doi.org/10.1021/acsnano.0c05026.
- (81) Colburn, S.; Zhan, A.; Majumdar, A. Tunable Metasurfaces via Subwavelength Phase Shifters with Uniform Amplitude. *Sci. Rep.* **2017**, *7* (1), 40174. https://doi.org/10.1038/srep40174.
- (82) Wei, Z.; Cao, Y.; Su, X.; Gong, Z.; Long, Y.; Li, H. Highly Efficient Beam Steering with a Transparent Metasurface. *Opt. Express* **2013**, *21* (9), 10739. https://doi.org/10.1364/OE.21.010739.
- (83) Butakov, N. A.; Knight, M. W.; Lewi, T.; Iyer, P. P.; Higgs, D.; Chorsi, H. T.; Trastoy, J.; Del Valle Granda, J.; Valmianski, I.; Urban, C.; Kalcheim, Y.; Wang, P. Y.; Hon, P. W. C.; Schuller, I. K.; Schuller, J. A. Broadband Electrically Tunable Dielectric Resonators Using Metal–Insulator Transitions. ACS Photonics 2018, 5 (10), 4056–4060. https://doi.org/10.1021/acsphotonics.8b00699.
- (84) Mancini, A.; Gubbin, C. R.; Berté, R.; Martini, F.; Politi, A.; Cortés, E.; Li, Y.; De Liberato, S.; Maier, S. A. Near-Field Spectroscopy of Cylindrical Phonon-Polariton Antennas. ACS Nano 2020, 14 (7), 8508–8517. https://doi.org/10.1021/acsnano.0c02784.
- (85) Schuller, J. A.; Brongersma, M. L. General Properties of Dielectric Optical Antennas. *Opt. Express* 2009, 17 (26), 24084. https://doi.org/10.1364/OE.17.024084.
- (86) Decker, M.; Staude, I.; Falkner, M.; Dominguez, J.; Neshev, D. N.; Brener, I.; Pertsch, T.; Kivshar, Y. S. High-Efficiency Dielectric Huygens' Surfaces. Adv. Opt. Mater. 2015, 3 (6), 813–820. https://doi.org/10.1002/adom.201400584.
- (87) Lewi, T.; Evans, H. A.; Butakov, N. A.; Schuller, J. A. Ultrawide Thermo-Optic Tuning of PbTe Meta-Atoms. *Nano Lett.* **2017**, *17* (6), 3940–3945. https://doi.org/10.1021/acs.nanolett.7b01529.
- (88) Xifré-Pérez, E.; Shi, L.; Tuzer, U.; Fenollosa, R.; Ramiro-Manzano, F.; Quidant, R.; Meseguer, F. Mirror-Image-Induced Magnetic Modes. ACS Nano 2013, 7 (1), 664–668. https://doi.org/10.1021/nn304855t.
- (89) Park, K.; Beule, C. De; Partoens, B. The Ageing Effect in Topological Insulators: Evolution of the Surface Electronic Structure of Bi 2 Se 3 upon K Adsorption. *New J. Phys.* 2013, 15 (11), 113031. https://doi.org/10.1088/1367-2630/15/11/113031.
- (90) West, D.; Sun, Y. Y.; Wang, H.; Bang, J.; Zhang, S. B. Native Defects in Second-Generation Topological Insulators: Effect of Spin-Orbit Interaction on Bi₂Se₃. *Phys. Rev. B* 2012, *86* (12), 121201. https://doi.org/10.1103/PhysRevB.86.121201.
- (91) Wang, S.; Zhang, P. Native Point Defects in Bi₂Se₃: A First-Principles Study. *Phys. Lett. A* 2020, 384 (14), 126281. https://doi.org/10.1016/j.physleta.2020.126281.
- (92) Aguilar, R. V.; Wu, L.; Stier, A. V.; Bilbro, L. S.; Brahlek, M.; Bansal, N.; Oh, S.; Armitage, N. P. Aging and reduced bulk conductance in thin films of the topological insulator Bi₂Se₃. J. Appl. Phys. 2013, 113 (15), 153702. https://doi.org/10.1063/1.4801911.

Supporting information

High-Index Topological Insulator Resonant Nanostructures from Bismuth Selenide

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1. CVD growth of bismuth selenide nanobeams

Nanobeams (NBs) of Bi₂Se₃ were synthesized by the technique of chemical vapor deposition (CVD) on a c-cut Sapphire [0001] substrate in a tube furnace inside a quartz tube. Before subjecting to CVD, the substrate surface was pre-treated in an ultrasonic bath with acetone and isopropyl alcohol for 5 mins to remove any contaminants. Organic leftovers from the surface were then cleaned using a solution of sulphuric acid and hydrogen peroxide (H₂SO₄:H₂O₂) in a ratio of 3:1 at 90 °C for 15 mins, followed by washing in deionized water. For the CVD process, powder of Bi₂Se₃ (Alfa Aesar-99.999%) was used as the precursor. To begin the synthesis, an inert atmosphere inside the tube was maintained by flowing 25 sccm (standard cubic centimeter per minute) of nitrogen. The substrate was then maintained at a temperature of 400 °C. Growth of the NBs was then carried out at 590 °C (ramp rate of 20 °C/min) for 3 hrs.

2. XRD peaks of Bi₂Se₃ NB

The peaks are observed at $2\theta \sim 17^{\circ}$, 25.3° , 33.9° , 38° , 40.9° , 42.5° , 43.7° , 48.2° , 50.9° and 51.5° which correspond respectively to the (006), (101), (107), (018), (1010), (0111), (110), (116), (021) and (024) planes of Bi₂Se₃.

3. Atomic force microscopy of Bi₂Se₃ NB



Figure S1. Atomic force microscopy (AFM) image of (a) Bi_2Se_3 NB and its (b) corresponding height (*h*) and width (*w*) extracted from three different locations, 1, 2, and 3.

4. Far-field spectroscopy



Figure S2. (a) Schematic illustration of far-field single particle infrared (IR) microspectroscopy (BS refers to beamsplitter & MCT to Mercury-Cadmium-Telluride detector). (b) Mid-IR reflectance spectra (experimental and fitted) of a Bi₂Se₃ flake of thickness ~485 nm. The sharp peak in the experimental spectra at ~4.2 μ m is due to atmospheric CO₂ absorption.

5. AFM of Bi₂Se₃ flakes



Figure S3. AFM image of (a) Bi₂Se₃ flake, and its (b) corresponding height extracted from three distinct locations, 1, 2, and 3.

6.	Oscillator	parameters
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Oscillator	ω ₀ (eV)	ω_p (eV)	γ (eV)
Drude	-	0.48	1.24E-6
Lorentz #1	0.5E-3	0.75	8.45
Lorentz #2	1.39	6.89	1.56

Table 1. The oscillators parameters ω_0 , ω_p , and γ , are respectively the transverse frequency, plasma frequency and scattering rate. The high-frequency dielectric constant (ε_{∞}) being 18.2.

7. Frequency-dependent permittivity of Bi₂Se₃

The spectral response for the variation of real (ε_r) and imaginary (ε_i) components of Bi₂Se₃ permittivity (ε) is shown in Figure S4.



Figure S4. Spectral dependence of Bi₂Se₃ permittivity.

From Figure S4 we see that in the NIR spectral range (<1.5µm) the material is dominated by significant absorption due to the large value of the imaginary part of permittivity (ε_i) where its comparable with the real part (ε_r). For longer wavelengths (λ >2µm), the real part (ε_r) is extremely high with much smaller values of the imaginary part (ε_i), defining a dielectric like behavior for the $\lambda \sim 2$ -12µm range.

8. Far-field simulations

The far-field scattering spectra of the single NB on Au substrate in the MIR optical regime was simulated using Ansys Lumerical's FDTD solver.¹ Considering the high aspect ratio of the NB (length/width ~40), we perform 2D simulations² to compute the simulated result, and then compare it with the experimental one. A simulation time of 1000 fs with auto non-uniform mesh under the mesh refinement of conformal variant 1 with a minimum mesh step of 0.00025 μ m was used. Furthermore, for obtaining better resolution at sharp geometrical discontinuities, an additional

uniform overriding mesh of 0.015 μ m was applied. A perfectly matched layer (PML) boundary condition (BC) was then used along both the axes, being placed ~2 λ_{max} (λ_{max} is the maximum wavelength of the sweep) away from the NB center. To illuminate the NB, a Total-Field scatteredfield (TFSF) source with 45° polarization was used as the incident electromagnetic source. Scattering cross-section was then computed using the "cross_section" analysis object, being placed in between the TFSF and PML. Scattering results were then achieved using the as-obtained frequency-dependent complex optical constants of Bi₂Se₃ and Lumerical's in-built constant of Au (Gold)-Palik. Finally, the electric and magnetic field components of the scattered field were recorded using a Frequency-domain field and power 2D-Z normal monitor.

9. Near-field simulations

The near-field optical amplitude and phase was simulated using the "grating_s_parameters" analysis object of Ansys Lumerical's FDTD solver. This analysis object uses a plane-wave as the source of excitation. Further, to better mimic the experimental conditions, an incidence angle of 45° was set for the excitation using Broadband Fixed Angle Source Technique (BFAST) plane-wave type.³ A 3D simulation was then set-up with a 2D monitor, placed 5 nm above the NB and parallel to the substrate plane (in this case a Perfect Electrical Conductor substrate, PEC) to record the frequency-dependent near-field amplitude and phase.³ Two sets of BCs were used to evaluate the near-field characteristics. Along the injection direction (z-direction) PML BC was used, while along the other two axes, PML (overridden by BFAST plane wave), Bloch (overridden by BFAST plane wave) and Symmetric BCs were used. Similar computational results were obtained for both these cases. The simulation volume was ~2 × 30.63 × 3.5 µm³, and, to ensure sufficient decay of the resonance field, a simulation time of 5000 fs was set.

10. Static tunability via size engineering



Figure S5. TM₁ mode evolution as a function of varying (a) height (*h*, fixed width) and (b) width (*w*, fixed height).

11. Near-field spectroscopy

Near-field measurements were performed by focusing a MIR beam both on the sample and the AFM tip using a parabolic mirror and then later collecting the backscattered light (Figure 4a and b, main text). The illuminated AFM probe creates a strong nano-focus on the sample and subsequently results in back-scattering (E_{scat}) (Figure 4a, main text). A pseudo-heterodyne detection mechanism is adopted in the system via the AFM cantilever being operated in the tapping mode. The backscattered light which then contains information of the local optical properties of the NB (amplitude and phase) is detected using a liquid nitrogen (LN₂) cooled MCT detector. The nanospectroscopy was performed with a broadband MIR laser (4.5–15 µm; FemtoFiber dichro midIR, Toptica) in an asymmetric interferometer configuration (Figure 4b, main text). Recorded interferogram is then Fourier transformed, and the scattered spectrum was then obtained by normalizing the NB spectrum with a reference spectrum, which in this case was Au spectrum (Figure 4d, main text).

12. Near-field amplitude and phase for varying *n* and fixed *k*

Case I: *k*=*k*_{cr} = 0.2

Figure S6 shows the near-field amplitude and phase as a function of varying n with fixed k as 0.2 (the critical value).



Figure S6. Near-field amplitude and phase for k = 0.2 and varying *n* as 5.5, 5.75, 6 and 6.5.

From the plot we see that increasing *n* from 5.5 to 6.5 red-shifts the resonance wavelength, as a typical Mie-resonance, however, the optical phase shift exhibits a large increase from $\Delta \varphi \sim \pi$ radians for *n*<6 to $\Delta \varphi \sim 2\pi$ for *n*≥6.

Case II: *k* = 0.39

Figure S7 presents the near-field amplitude and phase as a function of varying n with fixed k as 0.39 (obtained k-value around the resonance wavelength).



Figure S7. Near-field amplitude and phase for k = 0.39 and varying *n* varying from 5.0-6.5.

From the plot we see that increasing *n* from 5.0 to 6.5 red-shifts the resonance wavelength, as a typical Mie-resonance, however, the optical phase shift remains $<0.5\pi$, even for *n* going as high as 6.5.

Case III: k = 0

Figure S8 shows the near-field amplitude and phase for the case of a purely dielectric NB (k as 0). From the figure we see that, increasing n from 5.5 to 6.5 red-shifts the resonance wavelength, as a typical Mie-resonance, however, the optical phase shift remains pinned at $\sim 2\pi$, thus suggesting null effect of *n* variation on the optical phase shift for the case of a purely dielectric system.



Figure S8. Near-field amplitude and phase for k = 0 and varying *n* as 5.5, 6 and 6.5.

13. Near-field amplitude and phase for varying NB geometric dimensions

Figure S9 presents the variation of near-field amplitude and phase as a function of increasing the NB dimensions along *h* and *w*. Due to z-polarized excitation, effect of *h* variation should be dominant for controlling the phase shift, thus, we calculated the reflection amplitude and phase for a NB with $h = 0.4 \mu m$ and same *w* (0.7 μm). Increasing the NB *h* by 100 nm (~33%) resulted in red-shift of the resonance wavelength to ~6.3 μm and a phase shift of ~0.46 π radians (Figure S9a). Alternatively, fixing the *h* at 0.4 μm and increasing the *w* by 300 nm (~43%) led to a resonance wavelength of ~0.79 π radians (Figure S9b).



Figure S9. Near-field amplitude and phase for varying NB dimensions, (a) $h = 0.4 \mu m$, $w = 0.7 \mu m$, (b) $h = 0.4 \mu m$, $w = 1.0 \mu m$.

Increasing the NB dimensions red-shifts the resonance wavelength, as a typical Mie-resonance, with an achievable phase-shift of $\Delta \phi < \pi$ for resonance wavelengths at ~7.13 µm and below.

14. Near-field amplitude and phase for NBs supporting resonances at longer IR wavelengths

Figure S10 presents the near-field amplitude and phase for NBs supporting resonances in the longer wavelength regime, always exhibiting a near $\sim 2\pi$ optical phase-shift.



Figure S10. Near-field amplitude and phase for varying NB dimensions, (a) $h = 0.4 \mu m$, $w = 1.2 \mu m$, (b) $h = 0.4 \mu m$, $w = 1.5 \mu m$.

References

- (1) FDTD Solutions, Lumerical Solutions, Inc., http://www.lumerical.com.
- Wiecha, P. R.; Cuche, A.; Arbouet, A.; Girard, C.; Colas des Francs, G.; Lecestre, A.; Larrieu, G.; Fournel, F.; Larrey, V.; Baron, T.; Paillard, V. Strongly Directional Scattering from Dielectric Nanowires. ACS *Photonics* 2017, 4 (8), 2036–2046. https://doi.org/10.1021/acsphotonics.7b00423.
- (3) Mancini, A.; Gubbin, C. R.; Berté, R.; Martini, F.; Politi, A.; Cortés, E.; Li, Y.; De Liberato, S.; Maier, S. A. Near-Field Spectroscopy of Cylindrical Phonon-Polariton Antennas. ACS Nano 2020, 14 (7), 8508–8517. https://doi.org/10.1021/acsnano.0c02784.